

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 10/664,739
Filing Date September 18, 2003
Inventor Sujit Sharan et al.
Assignee Micron Technology, Inc.
Group Art Unit 2818
Examiner Dung Le
Attorney's Docket No. MI22-2340
Title: Methods for Conditioning Surfaces of Polishing Pads After
Chemical-Mechanical Polishing



SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

References –See Attached Form PTO-1449

The Examiner's attention is directed to the references which are listed on the attached Form PTO-1449, copies of which are attached. No admission is made regarding whether all the submitted references are prior art.

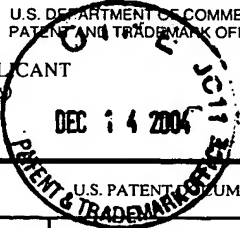
Citation of the referenced art is respectfully requested.

Respectfully submitted,

Dated: December 14, 2004

By: Jennifer J. Taylor
Jennifer J. Taylor, Ph.D.
Reg. No. 48,711

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Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE 		ATTY. DOCKET NO. MI22-2340		SERIAL NO. 10/664,739					
LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)				APPLICANT Sujit Sharan et al.							
				FILING DATE September 18, 2003		GROUP 2818					
U.S. PATENT DOCUMENTS											
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate				
	AA	5,970,373	10-1999	Allen							
	AB										
	AC										
	AD										
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	AF										
	AG										
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FOREIGN PATENT DOCUMENTS											
		Document Number	Date	Country	Class	Subclass	<table border="1" style="width: 100%; border-collapse: collapse;"> <tr> <th colspan="2">Translation</th> </tr> <tr> <td style="width: 50%;">Yes</td> <td style="width: 50%;">No</td> </tr> </table>	Translation		Yes	No
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Yes	No										
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OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)											
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